

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of:)	Group Art Unit: 1792
Yonhua Tzeng)	Examiner: Stouffer, Kelly M.
Serial No.: 10/772,740)	
Filed: February 5, 2004)	
For: METHOD OF PLASMA ENHANCED CHEMICAL VAPOR DEPOSITION OF DIAMOND USING METHANOL-BASED SOLUTIONS)	AMENDMENT AND REQUEST FOR CONTINUED EXAMINATION (RCE)
)	162 North Wolfe Road Sunnyvale, California 94086 (408) 530-9700
)	Customer No.: 28960

Mail Stop RCE
Commissioner for Patents
P.O. Box 1450
Alexandria, Virginia 22313-1450

AMENDMENTS

Sir:

Please amend the subject application as follows:

Amendments to the Claims are reflected in the listing of claims, which begins on page 2 of this paper.

Remarks/Arguments begin on page 7 of this paper.